

Electromagnetic Design of Diffractive, Micro Cavity, and Photonic Band Gap Devices

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Report Documentation Page

Form Approved
OMB No. 0704-0188

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1. REPORT DATE 18 APR 2000	2. REPORT TYPE N/A	3. DATES COVERED -	
4. TITLE AND SUBTITLE Electromagnetic Design of Diffractive, Micro-Cavity, and Photonic Band Gap Devices		5a. CONTRACT NUMBER	
		5b. GRANT NUMBER	
		5c. PROGRAM ELEMENT NUMBER	
6. AUTHOR(S)		5d. PROJECT NUMBER	
		5e. TASK NUMBER	
		5f. WORK UNIT NUMBER	
7. PERFORMING ORGANIZATION NAME(S) AND ADDRESS(ES) University of Delaware		8. PERFORMING ORGANIZATION REPORT NUMBER	
9. SPONSORING/MONITORING AGENCY NAME(S) AND ADDRESS(ES)		10. SPONSOR/MONITOR'S ACRONYM(S)	
		11. SPONSOR/MONITOR'S REPORT NUMBER(S)	
12. DISTRIBUTION/AVAILABILITY STATEMENT Approved for public release, distribution unlimited			
13. SUPPLEMENTARY NOTES DARPA/MTO, WDM for Military Platforms Workshop held in McLean, VA on April 18-19, 2000, The original document contains color images.			
14. ABSTRACT			
15. SUBJECT TERMS			
16. SECURITY CLASSIFICATION OF:			17. LIMITATION OF ABSTRACT
a. REPORT unclassified	b. ABSTRACT unclassified	c. THIS PAGE unclassified	UU
			18. NUMBER OF PAGES 21
			19a. NAME OF RESPONSIBLE PERSON



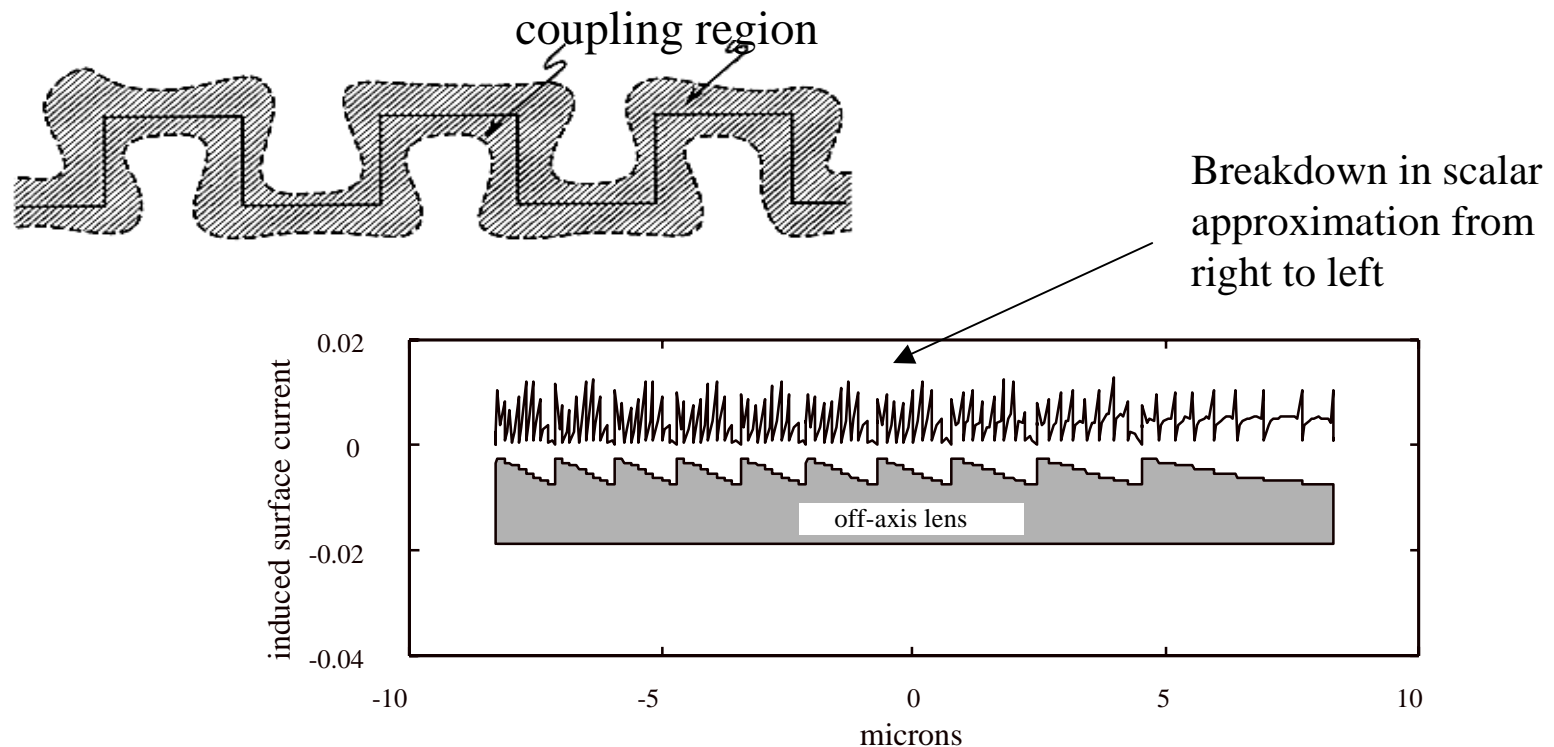
Outline

- Electromagnetic Analysis and Design of Micro-Photonic Devices
- Applications for WDM
 - Embedded spectrometer
 - Photonic band gap filtering
- Diffractive Optic Design for On-Axis Spectroscopy
 - $f/\#$ dependence chromatic dispersion
 - Wavelet based multiresolution optimization
 - Fabrication of meso-scopic grayscale DOEs
- Photonic Band Gap Filters
 - Band Gap Design for finite length PBGs
 - Cavity arrays for WDM
 - Active semiconductor modeling



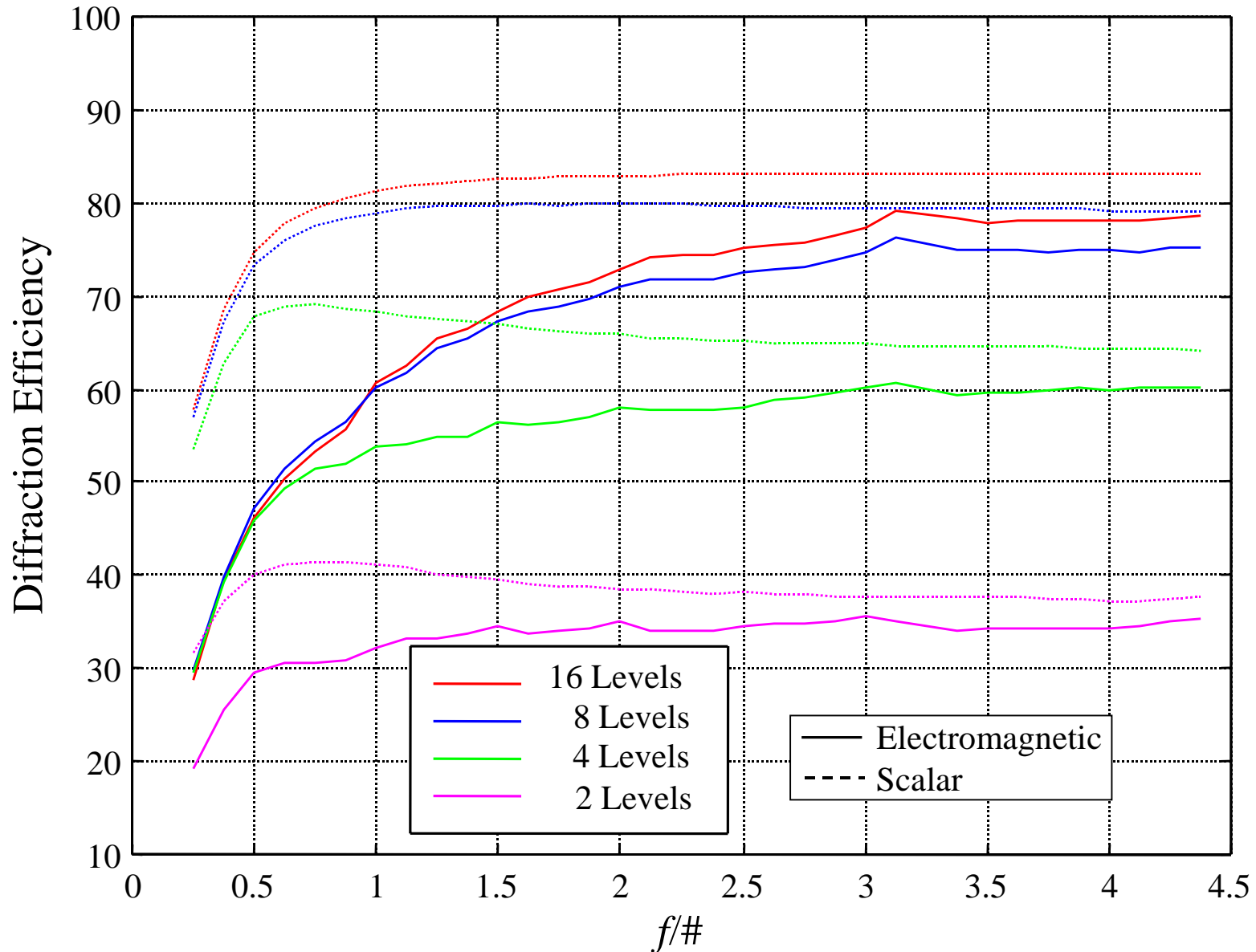
Why Electromagnetic Models Are Necessary

- As the scale of photonic devices approach the wavelength of operation boundary coupling effects significantly influence the EM fields on the boundary.
- This effect must be fully accounted for in the solution to the boundary value problem.
- This precludes the use of scalar and various other approximate methods.





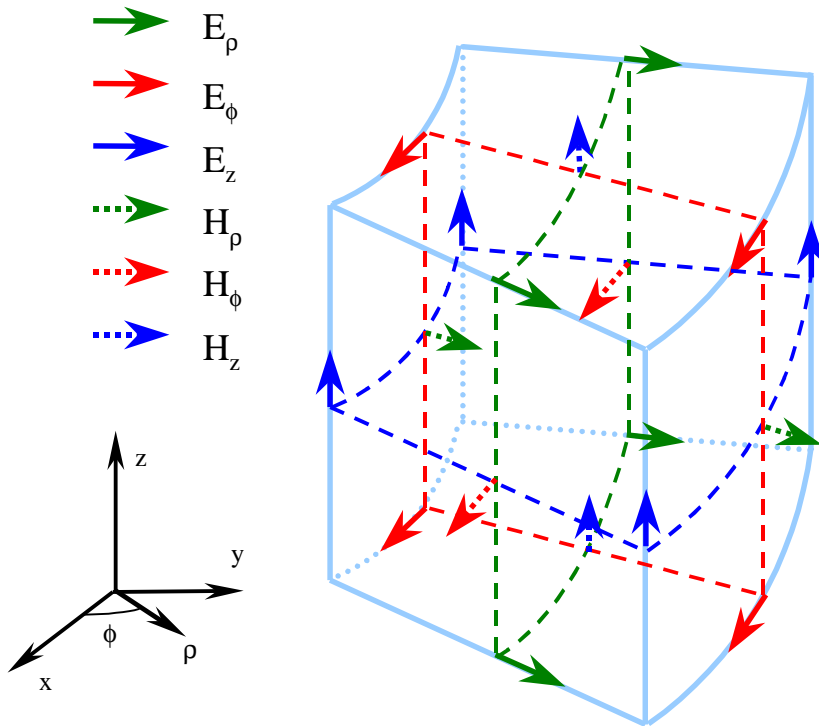
3D Diffractive Lens Analysis Results



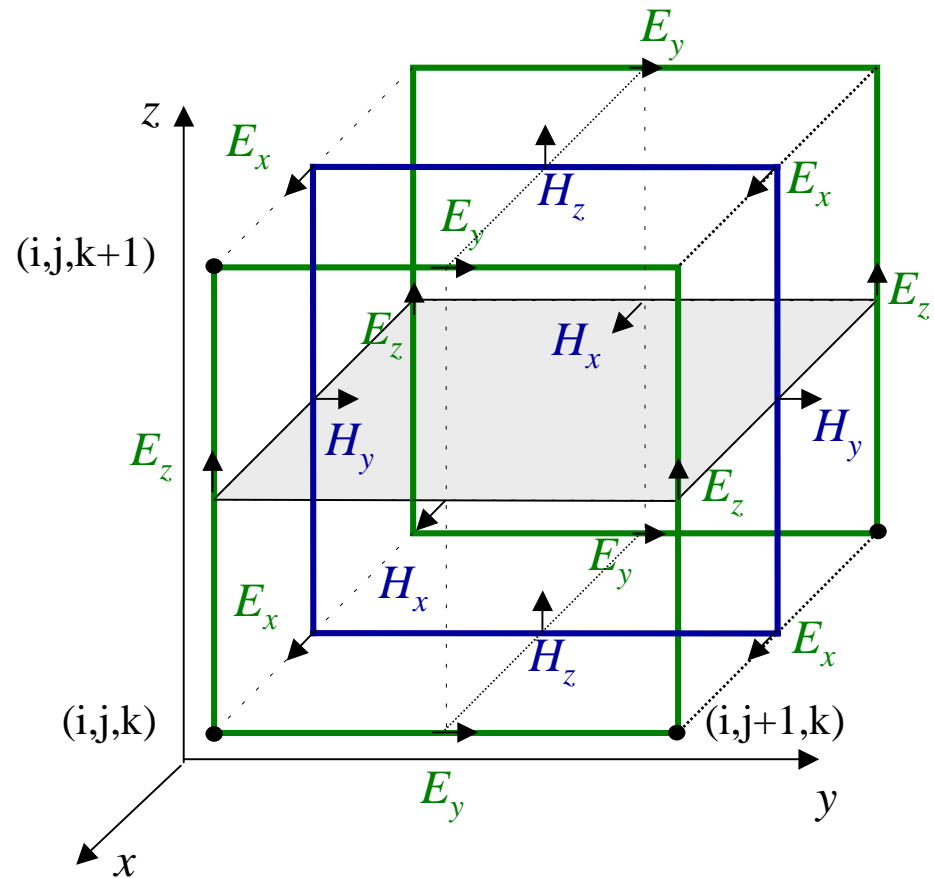


Computational Lattices In Three-Dimensions

BOR FDTD Unit Cell

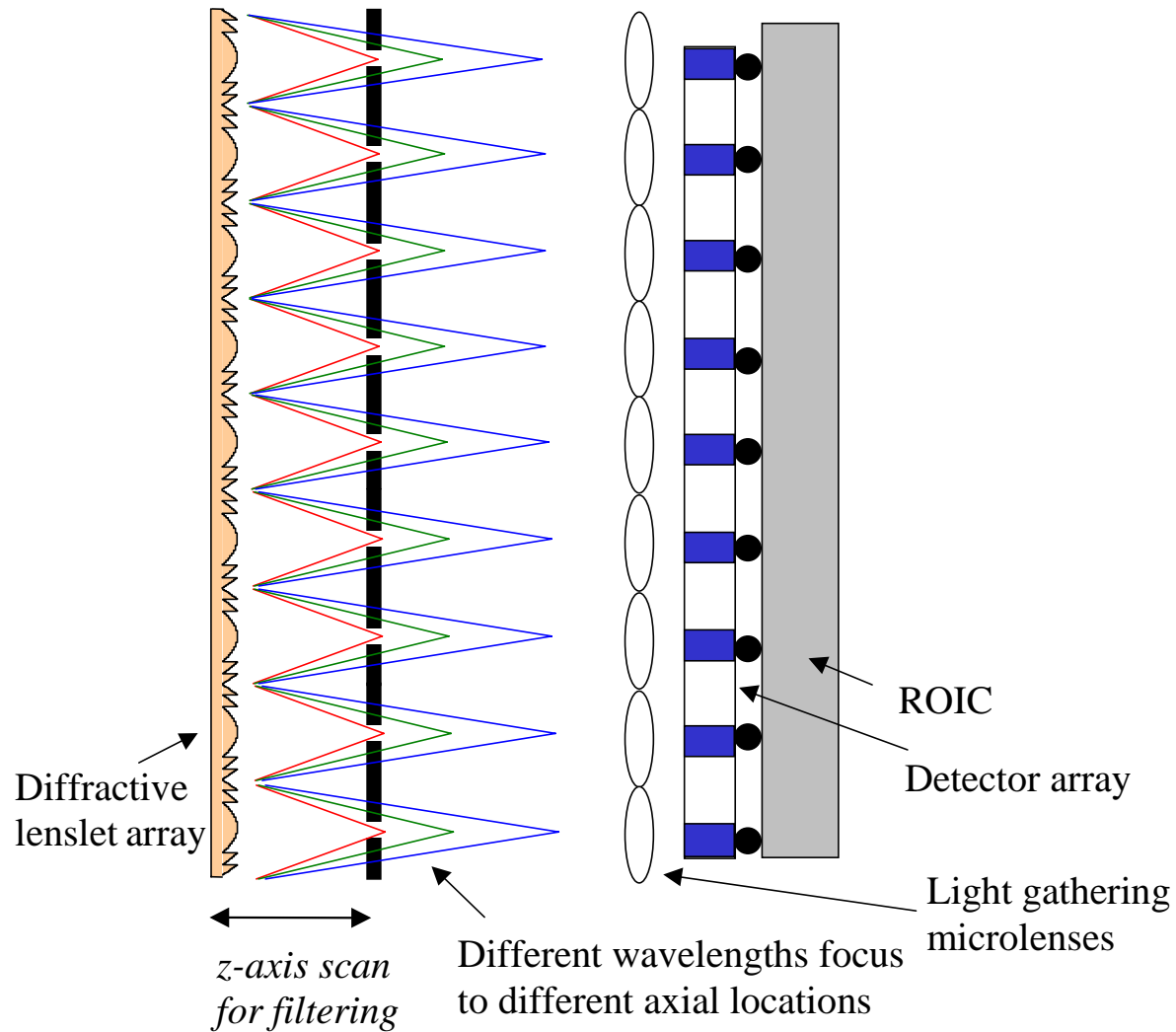


Full 3D FDTD





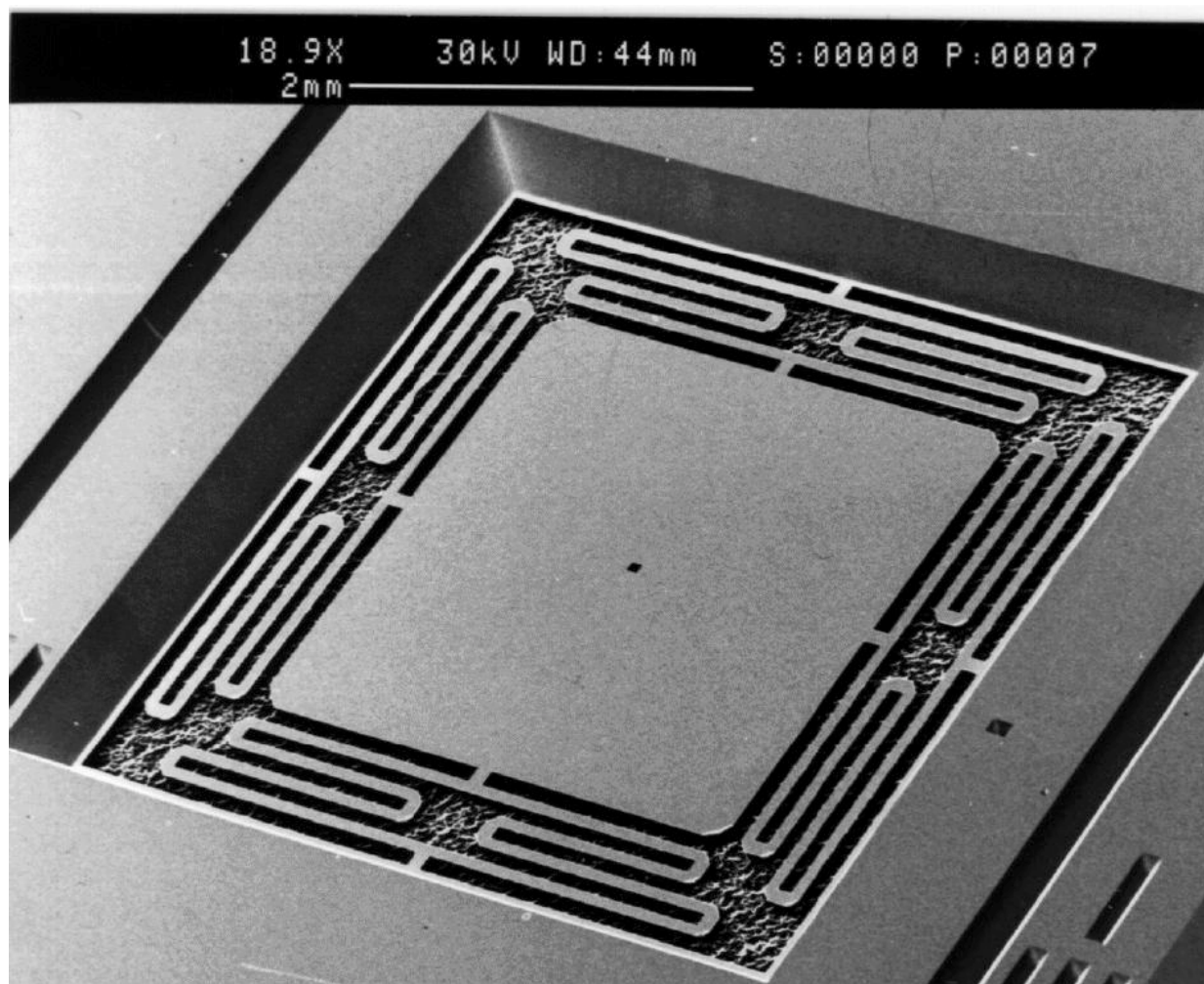
Application I: Embedded Spectrometer

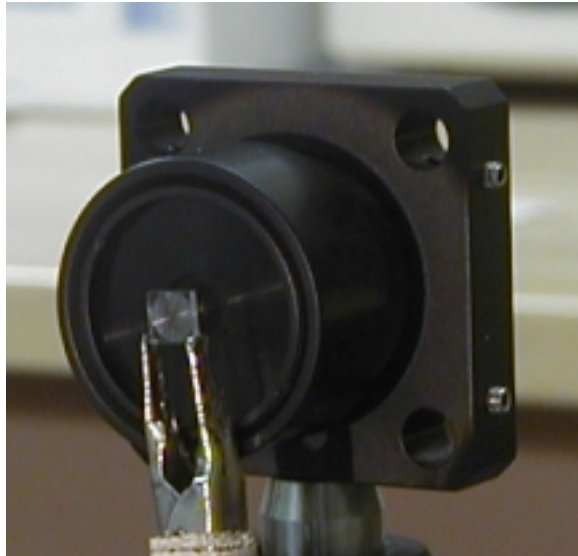




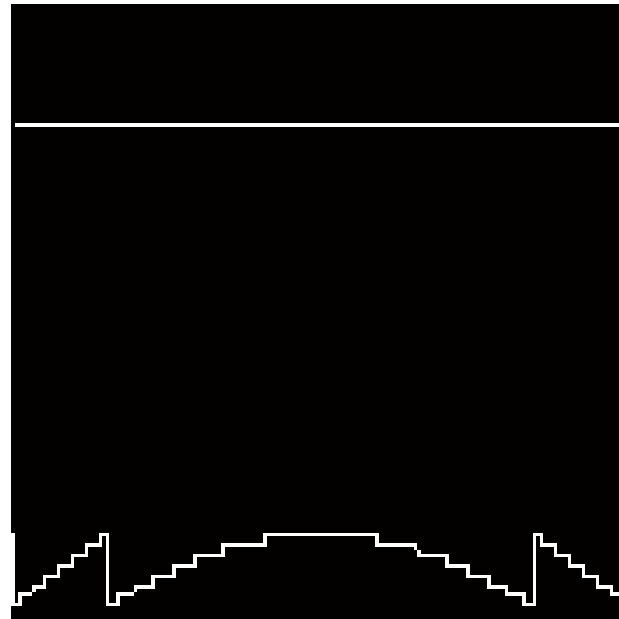
Application I: Scanner Development

Collaboration with Chemnitz University of Technology, Germany

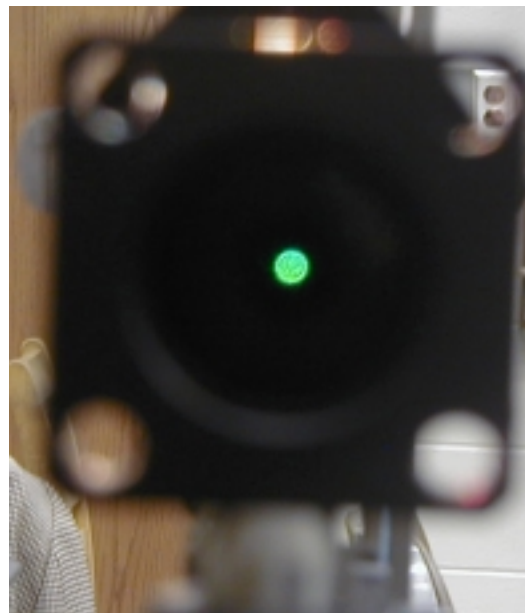




Spectrometer setup, $D = 5\text{mm}$, $f = 5\text{mm}$



7.86mm



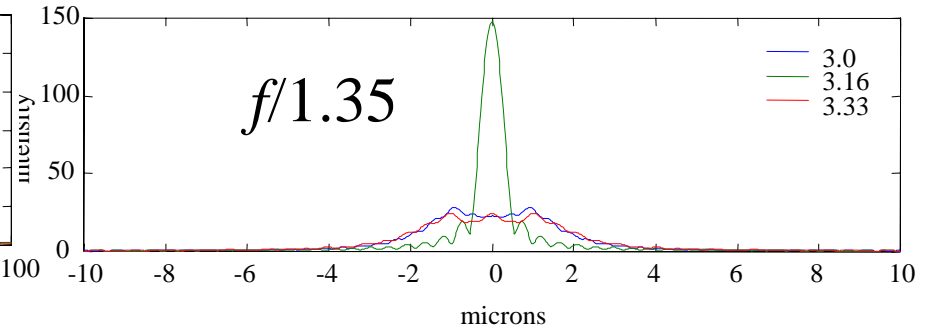
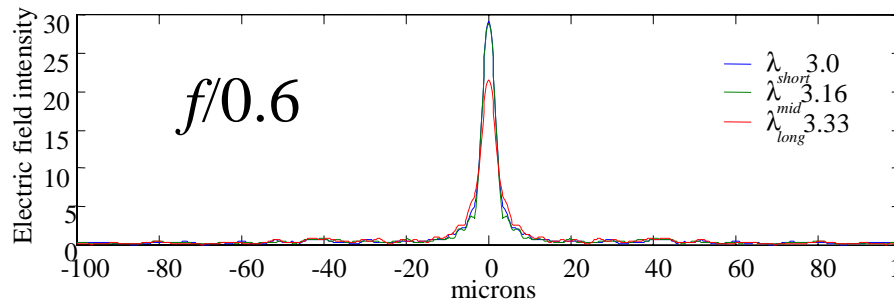
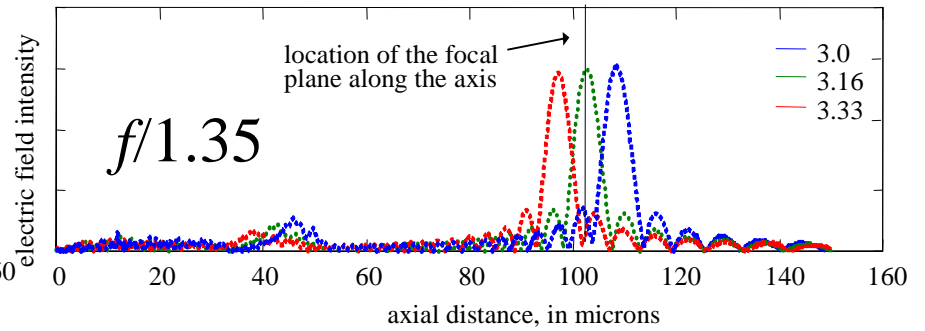
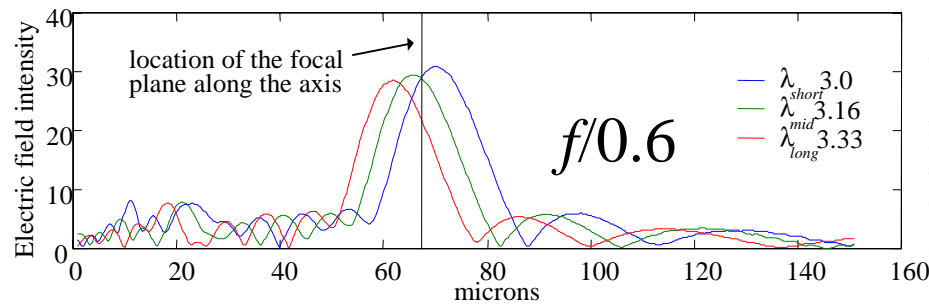
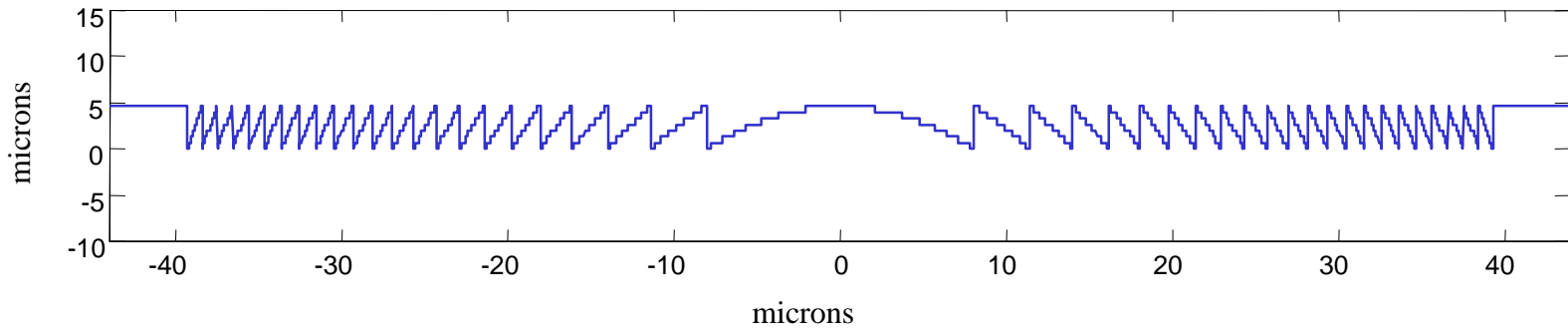
9.8mm



11.41mm

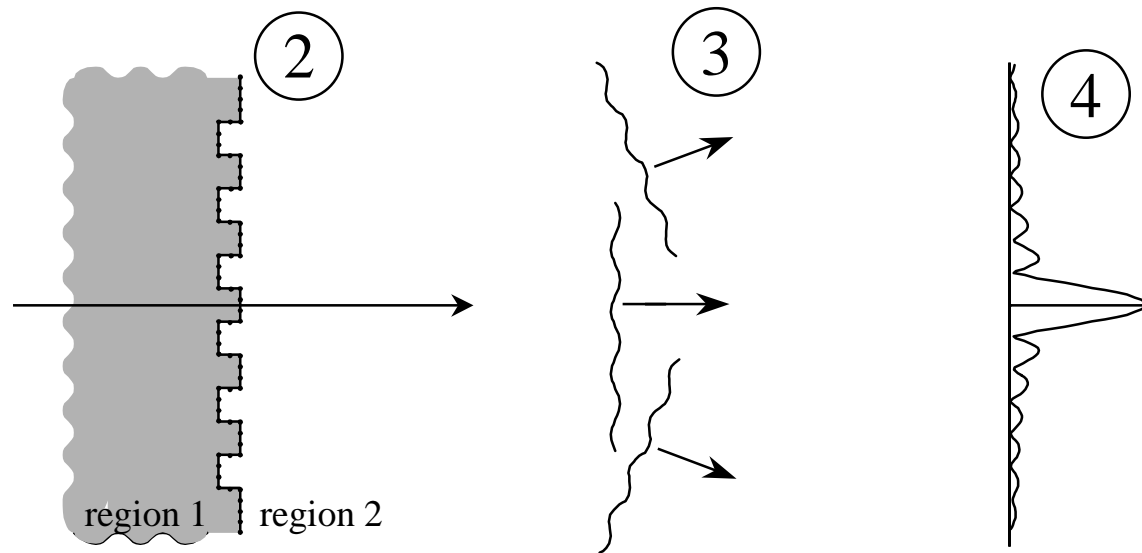


Application I: Lens Design





Electromagnetic-Based DOE Optimization

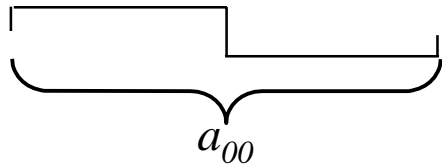


- Repeat
1. initial guess
 2. use rigorous electromagnetic model to analyze DOE
 3. evaluate performance
 4. optimize performance metric

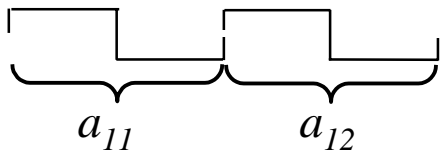


Wavelet-Based Optimization Method

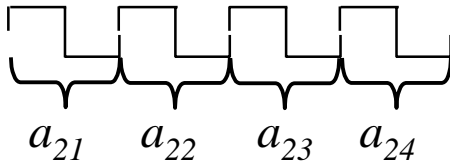
Wavelet Decomposition Process



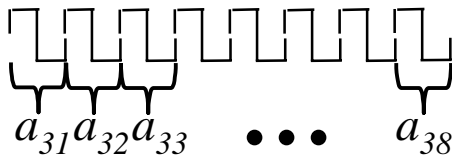
Zeroth order Haar Wavelet, $a_{00}\psi(x)$



First order Haar Wavelets, $a_{1m}\psi(2x - m)$

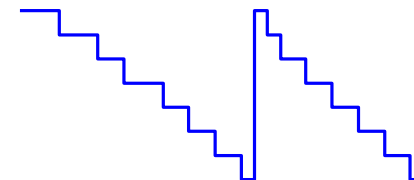
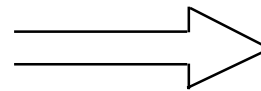


Second order Haar Wavelets, $a_{2m}\psi(2^2x - m)$



Third order Haar Wavelets, $a_{3m}\psi(2^3x - m)$

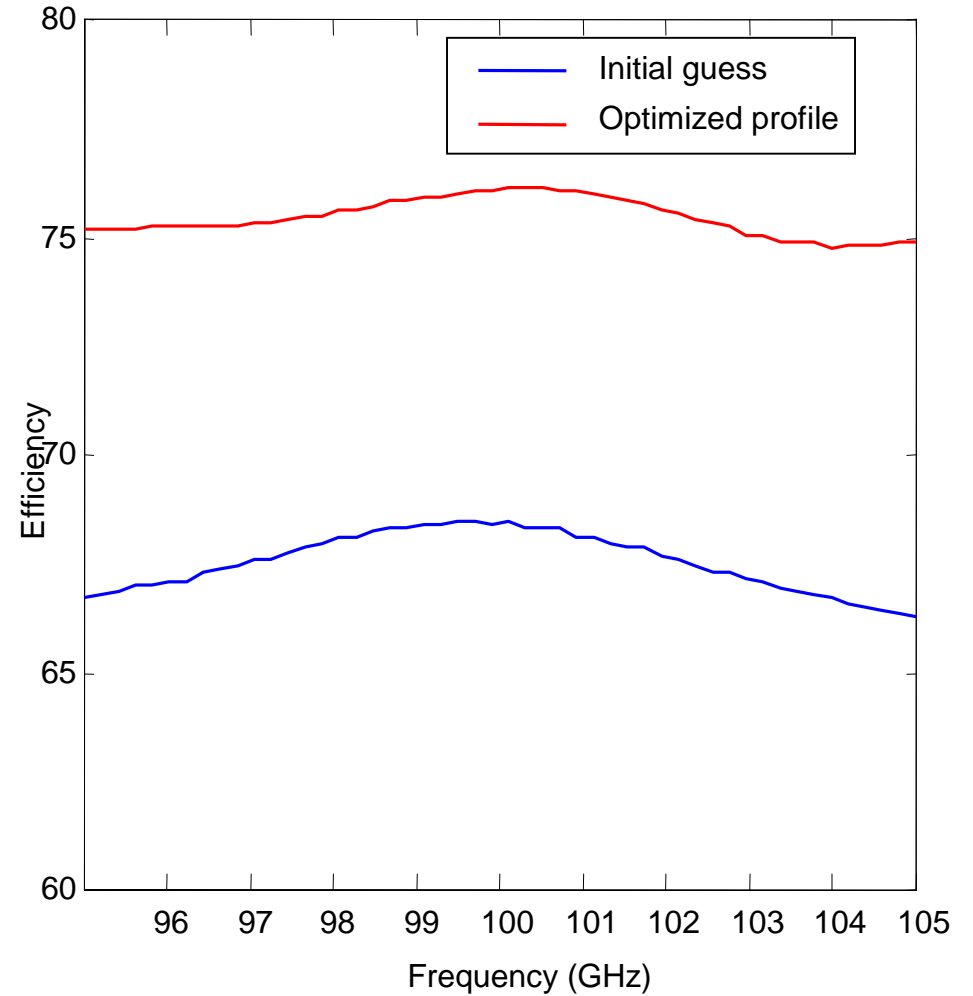
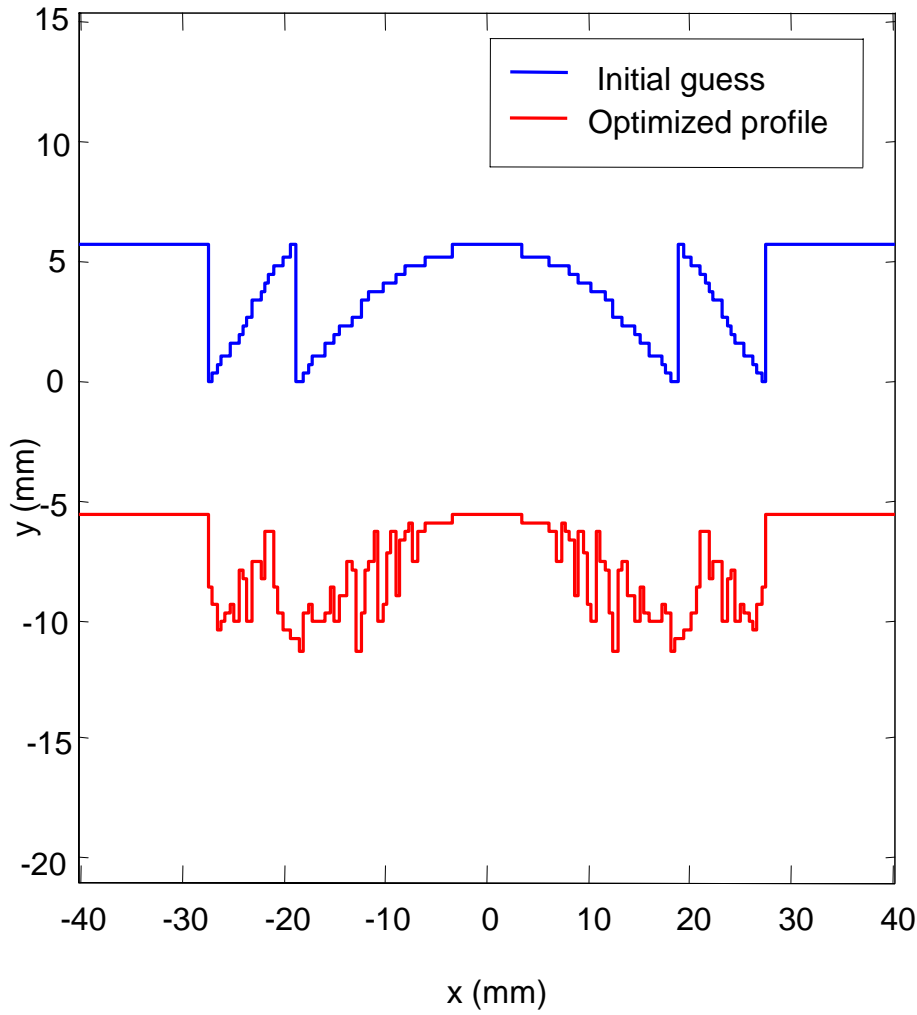
$$\sum_{n,m} a_{n,m} \psi(2^n x - m)$$



Diffractive Profile



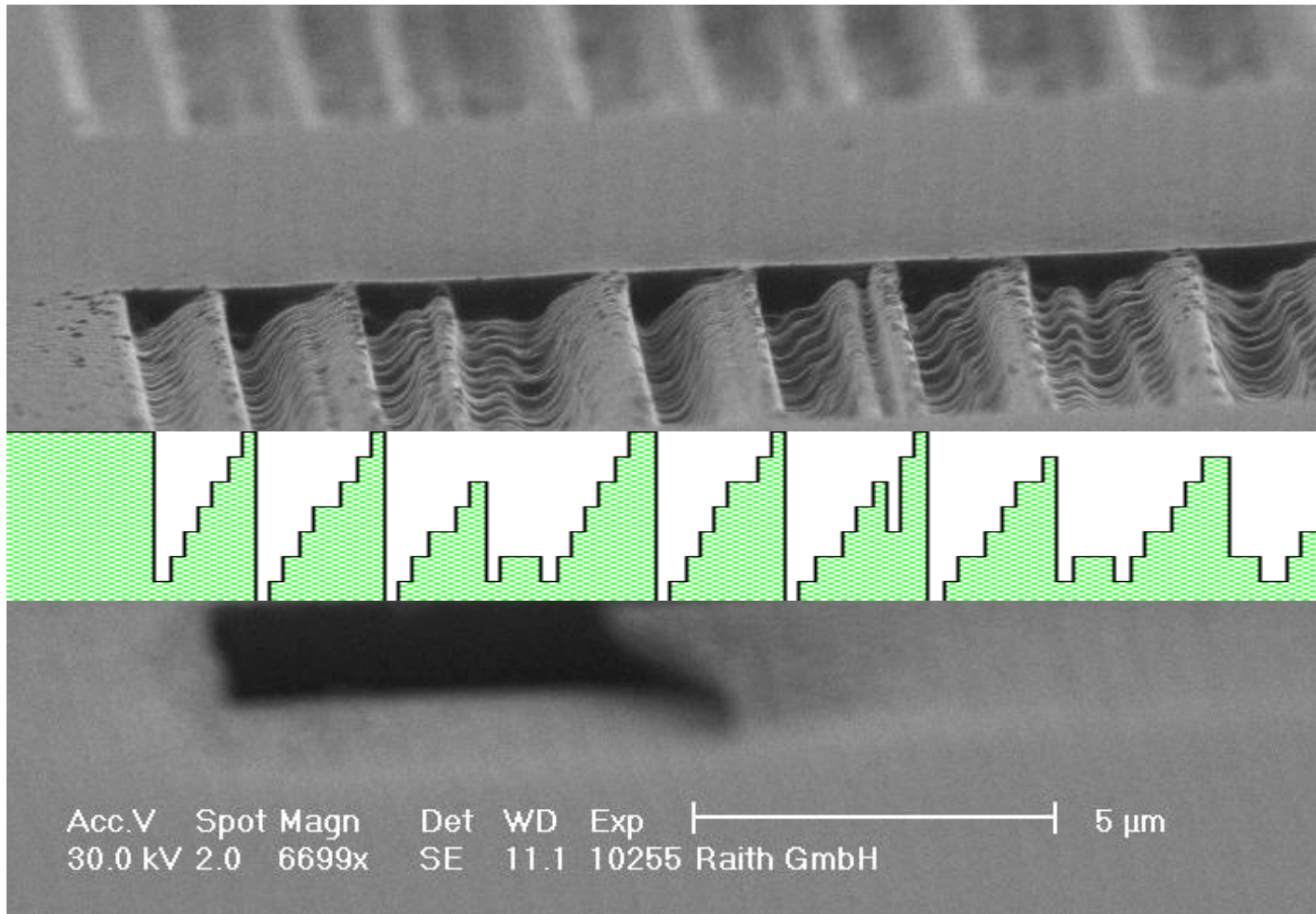
Profile and Efficiency Improvements





Fabrication of Grayscale Mesoscopic DOEs

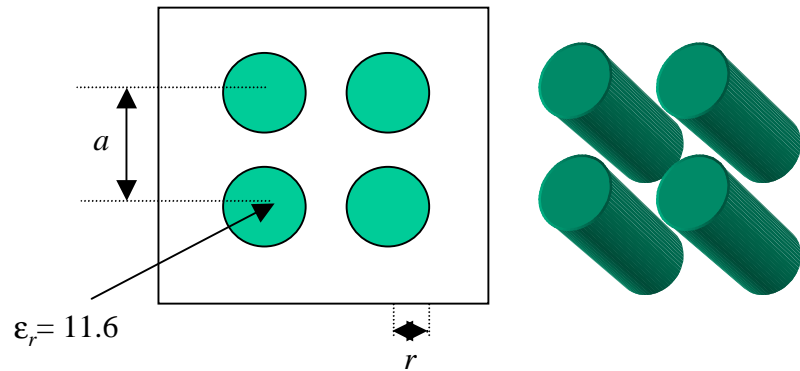
Outer zones of an 8-level EM optimized DOE



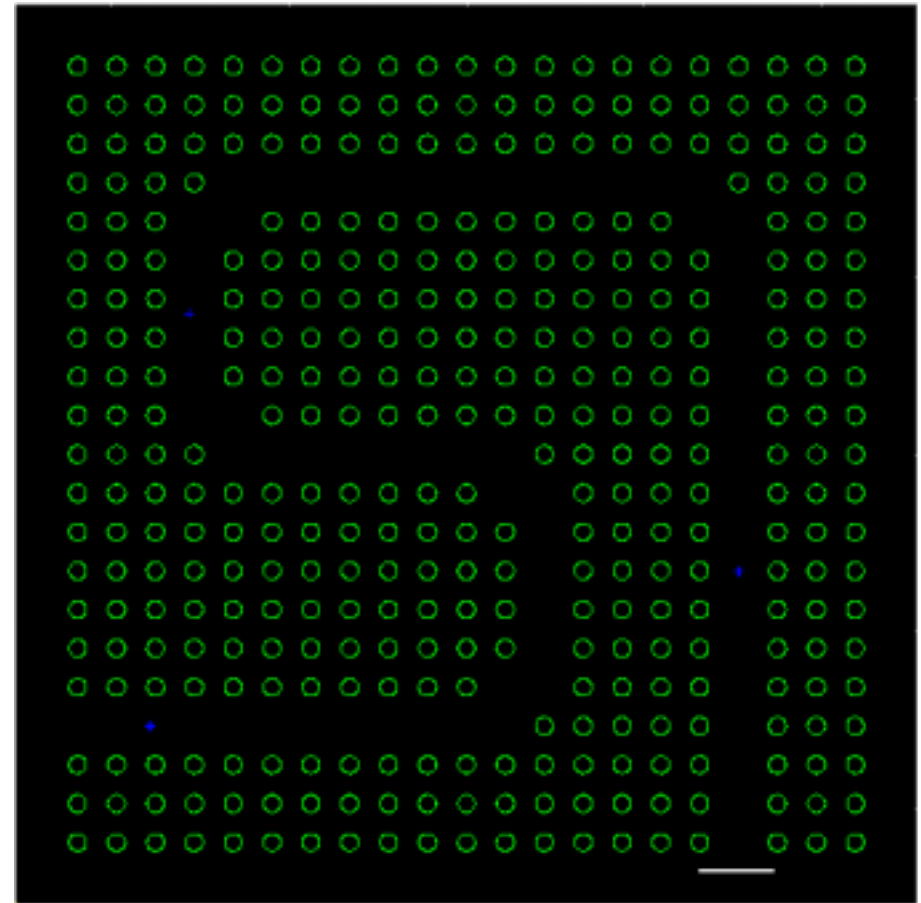
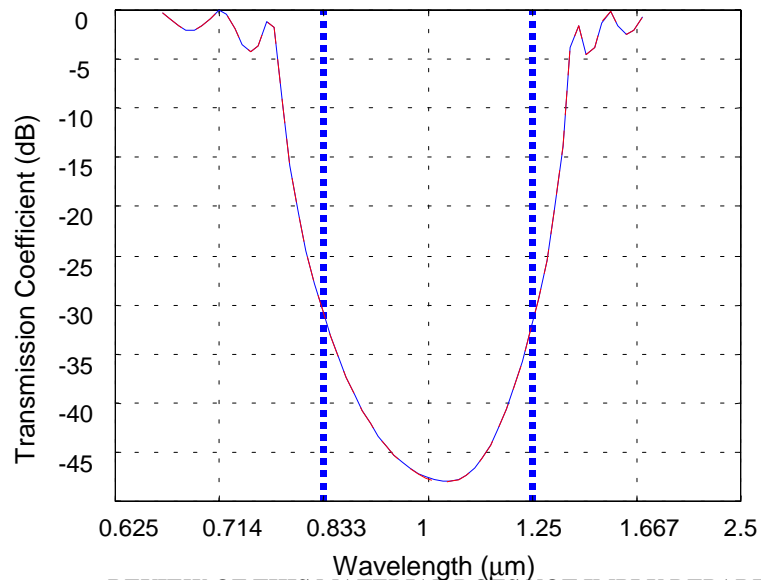


Application II: Photonic Band Gap Devices

- PBG's guide light based on the scattering properties created by tailoring the surface profile.
- They have a strong spectral dependence, which can be exploited in design.

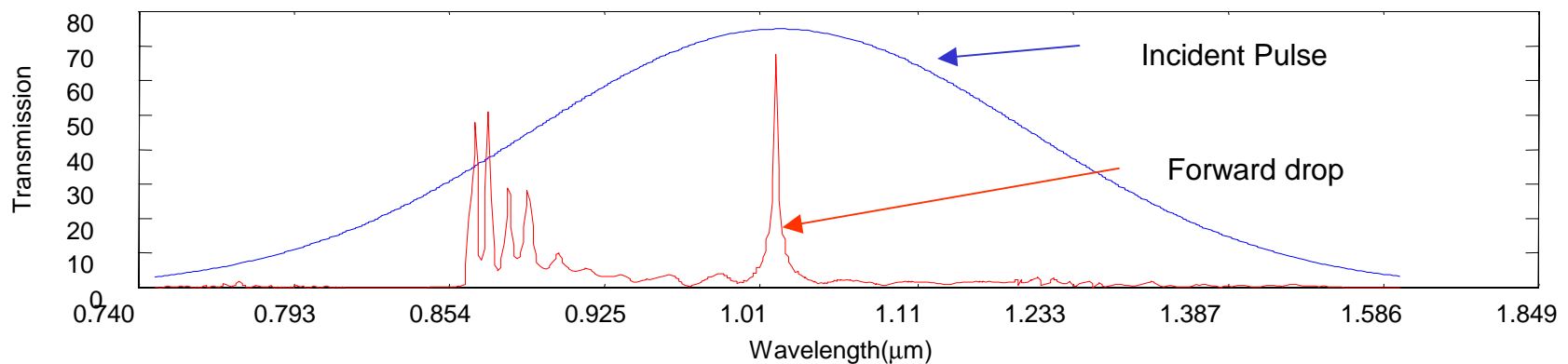
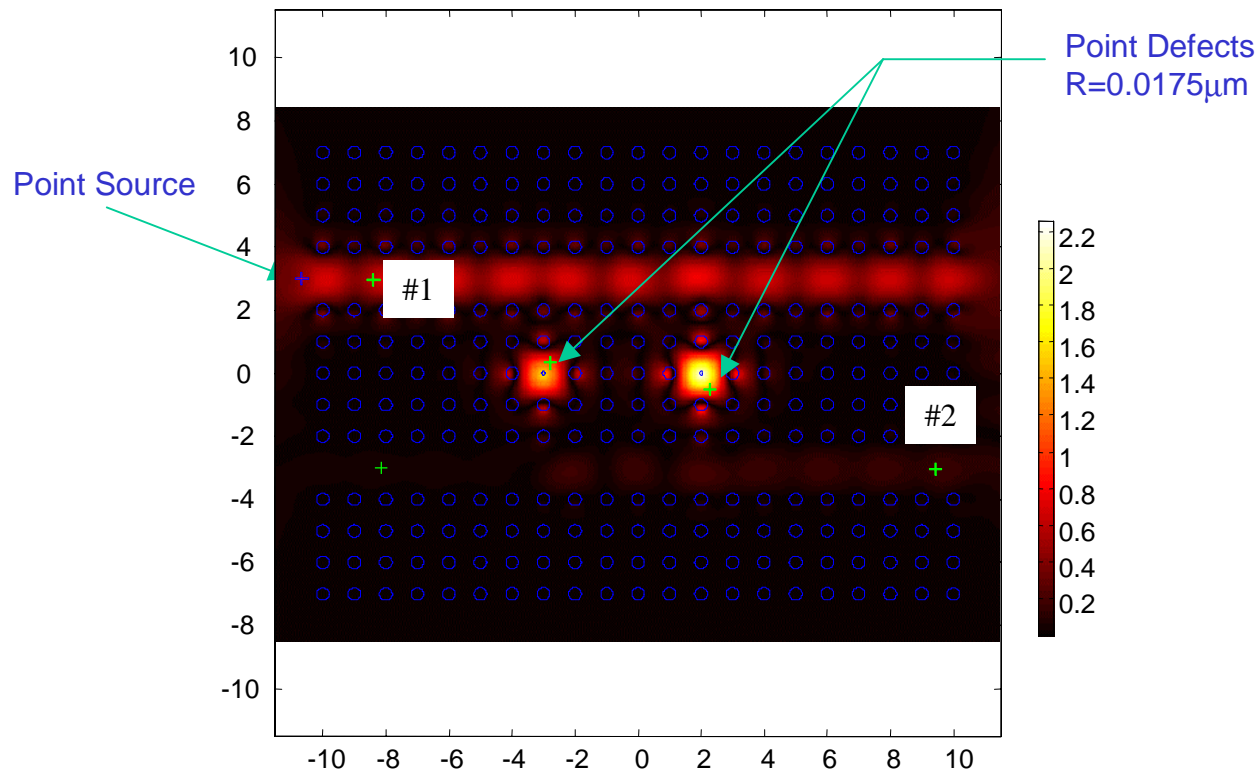


Rectangular Lattice: $a = 0.35 \mu\text{m}$, $r = 0.07 \mu\text{m}$



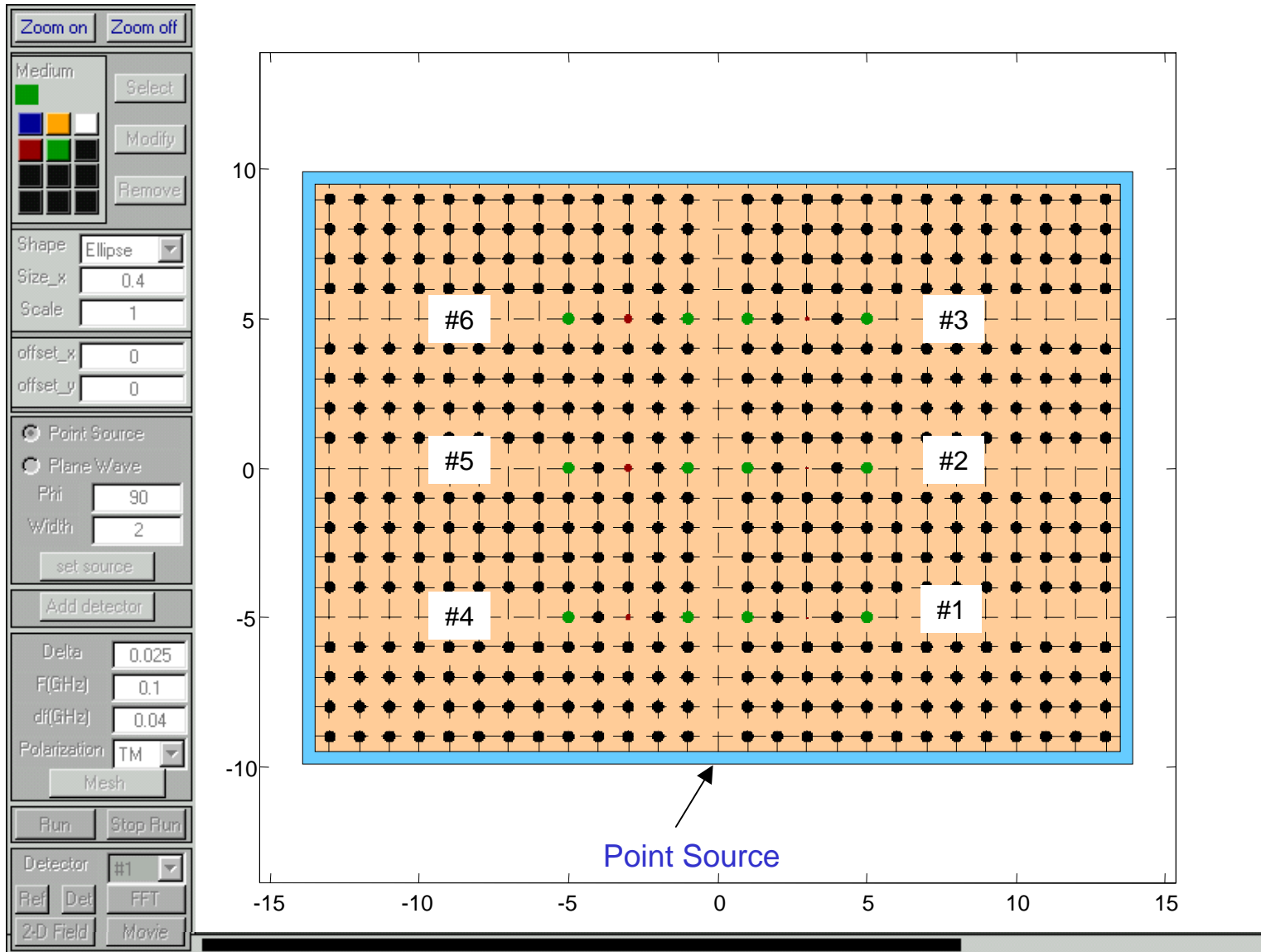


WDM Filtering using Two Cavities



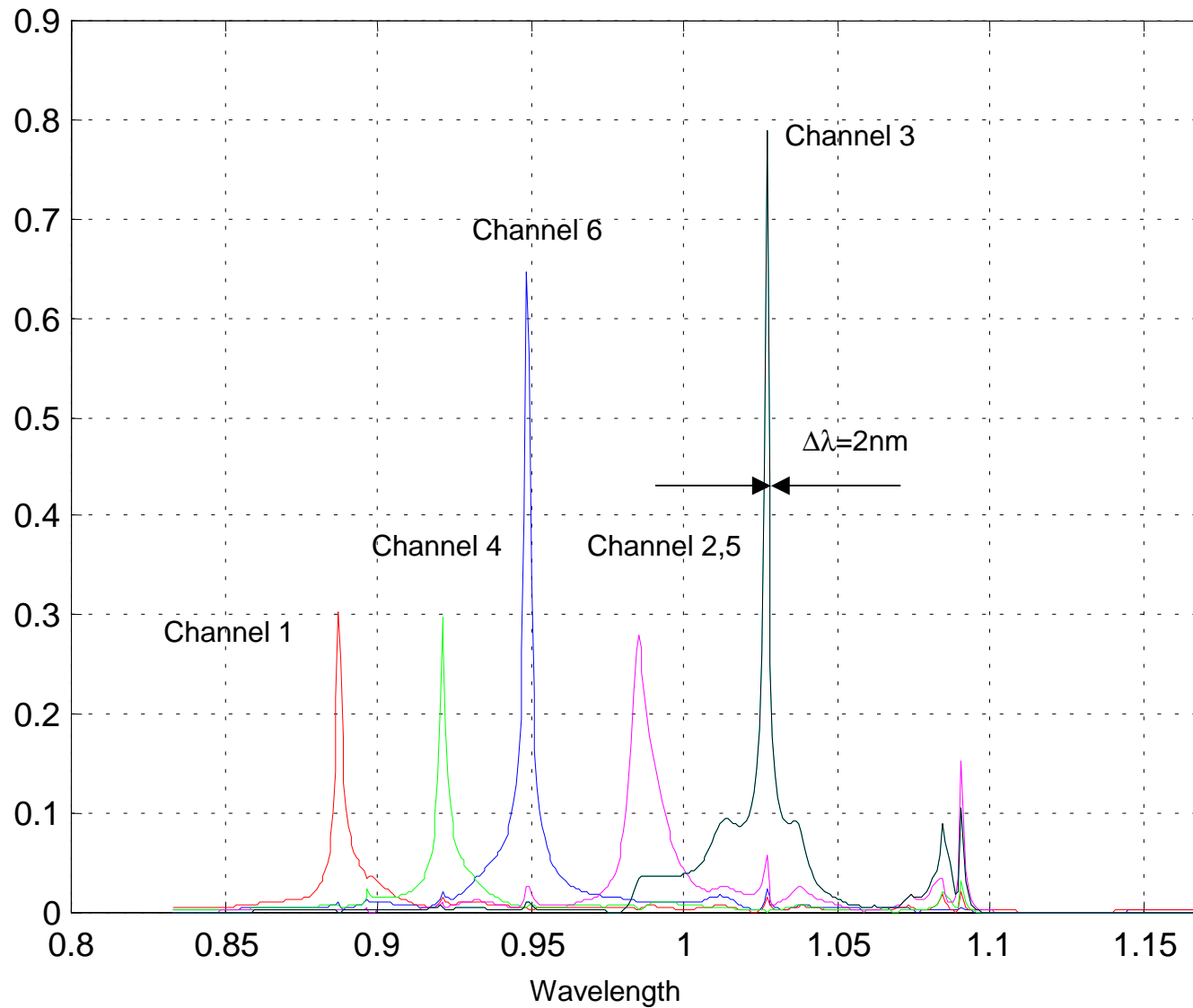


6 Channel WDM Filtering using Single Cavity Filters



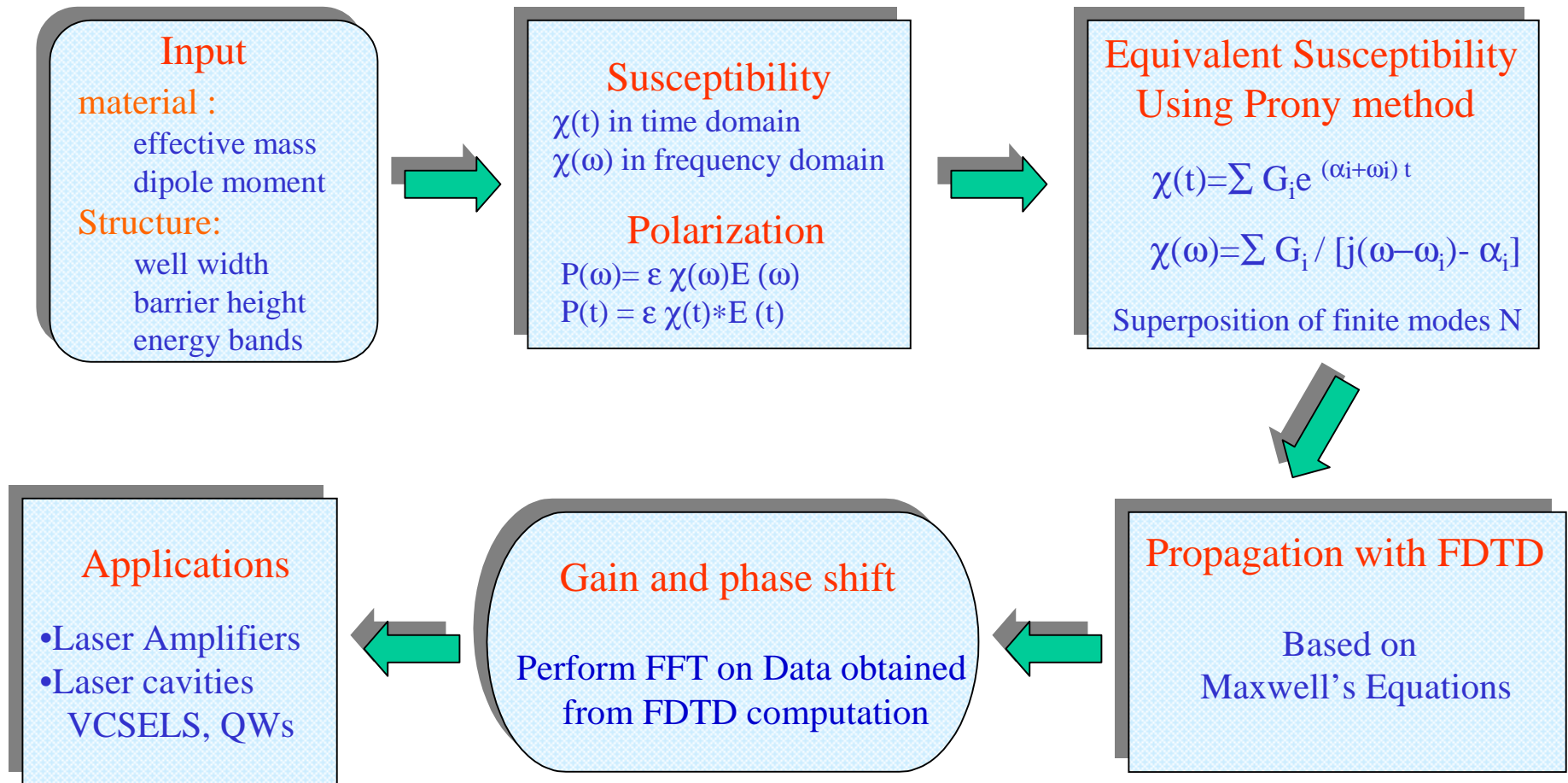


6 Channel WDM Filtering using Single Cavity Filters



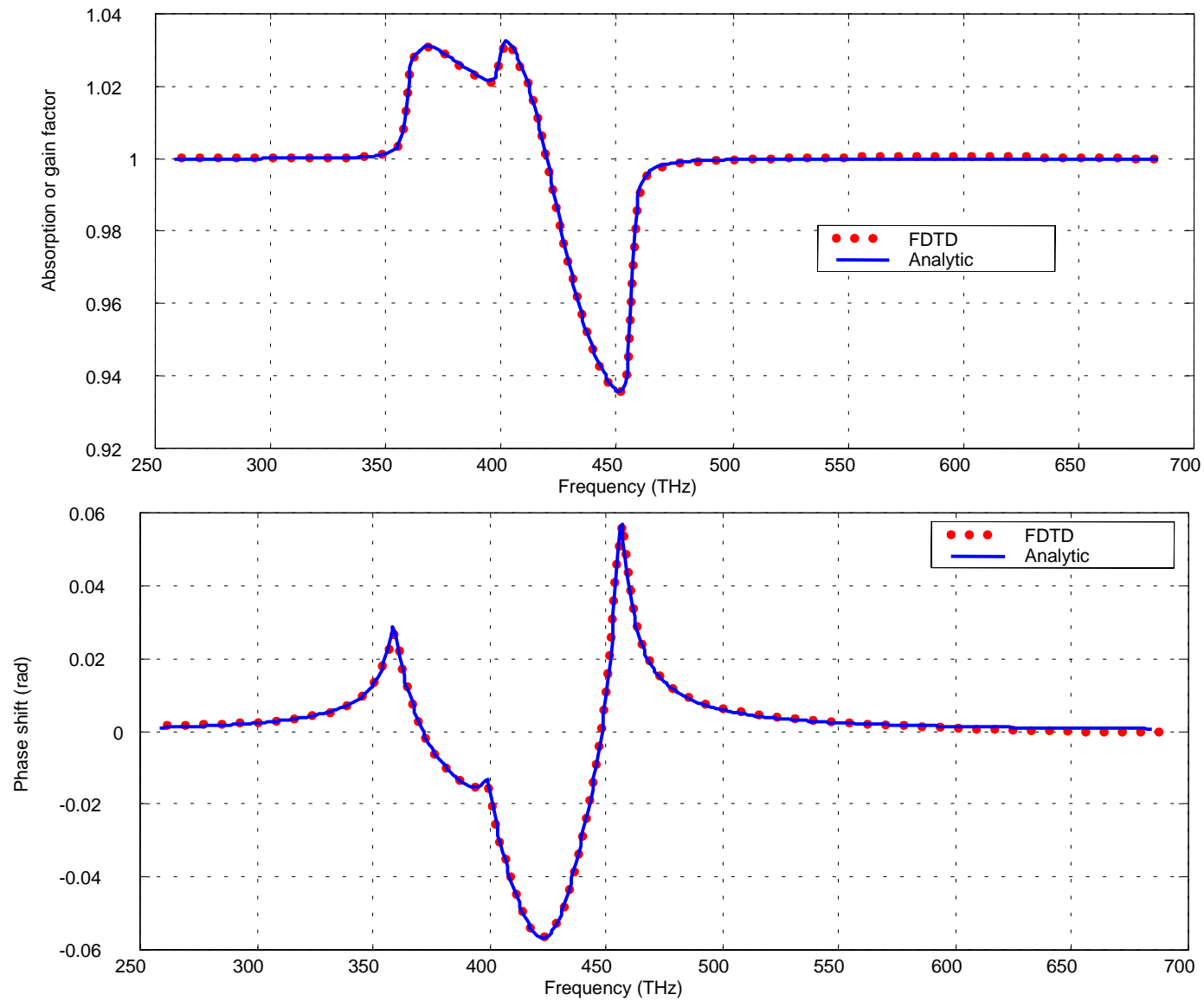


Parameterization Method for Semiconductor Amplifier





FDTD Results: $N = 12e18/cm^{-1}$





Semiconductor Gain Modeling in FDTD

GaAs :

Injected carrier: $N=9e24/m^{-3}$

Dephasing time: $T_2=0.1ps$

Central frequency: $f=3.52 \cdot 10^{14}Hz$

$A = -2.0896e+029$

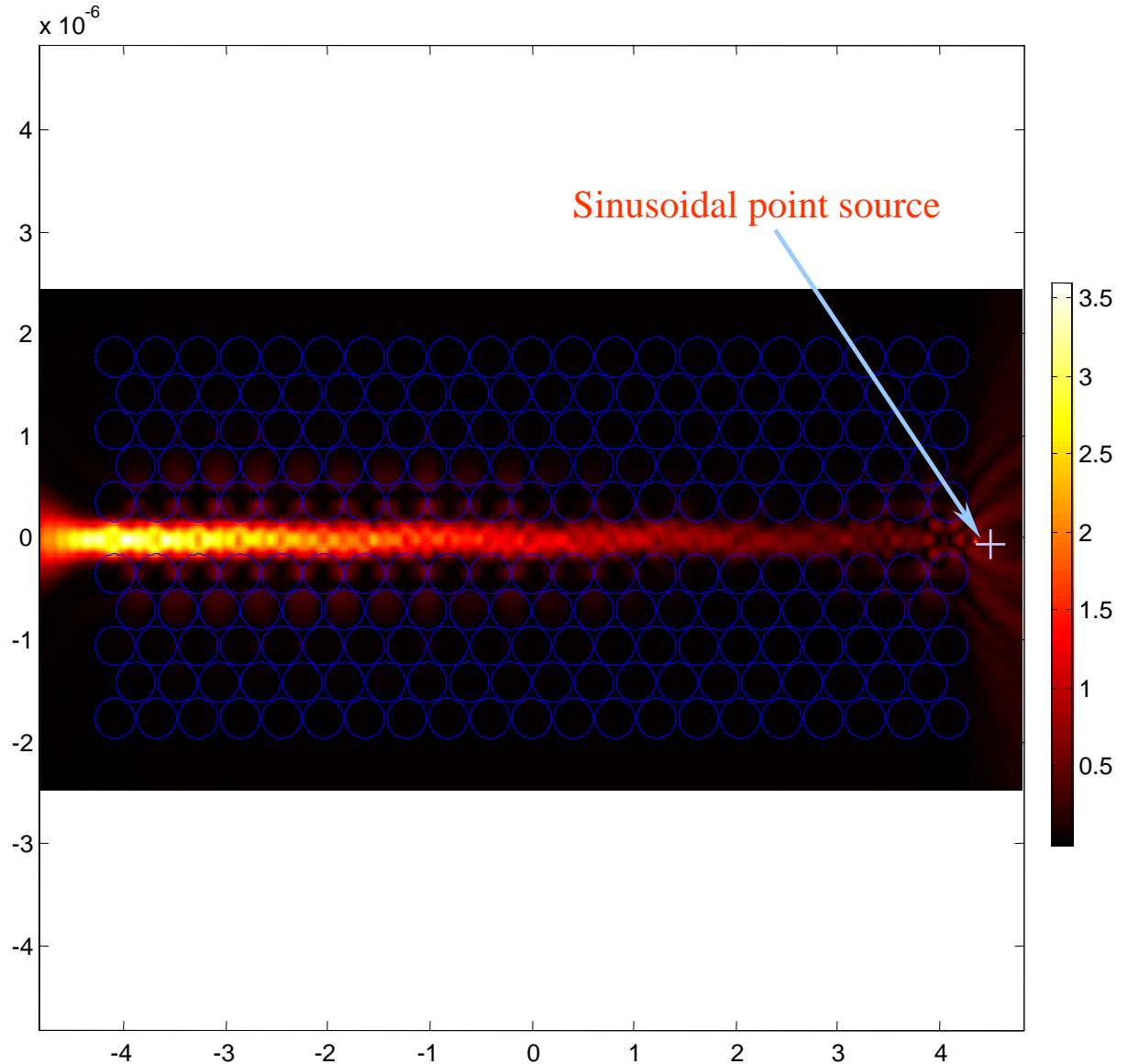
$B = -3.6279e+043$

$\omega_0 = 2.4125e+015$

$\omega_t = 1.7361e+014$

Equivalent conductivity

$$\sigma = (j \omega A+B)/(\omega^2_o - 2j\omega_o\omega-\omega^2)$$





Summary

- Discussed the electromagnetic analysis and design of diffractive lenses and photonic band gap devices.
- Presented two applications for WDM
 - Embedded spectrometer
 - Photonic band gap filtering
- Introduced Wavelet based multiresolution optimization of diffractive lenses.
- Showed $f/\#$ dependence chromatic dispersion and its effect on spectral filtering.
- Channel drop filters based on an array of single cavity photonic band gap channels.